L Number	Hits	Search Text	DB	Time stamp
1	70	(coat coating deposit depositing deposition film layer	USPAT;	2004/06/03 14:01
		layering) near3 (silicon near (carbide nitride oxide dioxide)	US-PGPUB;	
		"si.sub.3.N.sub.4" "si.sub.3 n.sub.4" "sio.sub.2" "si O.sub.2"	EPO; JPO;	
		"SiC" "Si C") and ((438/121,122,for.436).CCLS.) and	DERWENT;	
		pd>=20040311	IBM_TDB	